



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

Shin KUWABARA

Serial Number: 10/026,906

Group Art Unit: 1711

Filed: December 27, 2001

Examiner: Unknown

For: NEAR INFRARED ABSORPTION MATERIAL

**TRANSMITTAL OF ENGLISH LANGUAGE TRANSLATION
OF PRIORITY APPLICATION & STATEMENT**

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Assistant Commissioner
for Patents
Washington, D.C. 20231

August 7, 2002

Sir:

Applicants submit herewith an English language translation of the Japanese priority application, Japanese Patent Application No. 2000-400914, for the United States patent application identified above, with a statement that the translation is accurate. A claim to priority was filed on December 27, 2001.

In the event any fees are required, please charge our Deposit Account No. 111833.

Respectfully submitted,

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Enclosure: English Language Translation of Priority
Application w/ Statement

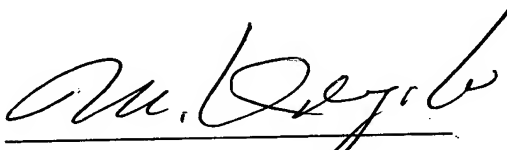


Statement

I, Masato Kobayashi, hereby state that I am competent in both the Japanese and English languages and that the attached English language document is an accurate translation of Japanese patent Application No. 2000-400914.

July 26, 2002

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Masato Kobayashi



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This is to certify that the annexed is a true copy of the
following application as filed with this Office.

Date of Application: 28th day of December, 2000

Application Number: Patent Application No. 2000-400914

Applicant: Nisshinbo Industries, Inc.

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6th day of September, 2001

Commissioner, Patent Office

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(Filing Date) December 28, 2000
(To:) Commissioner, Patent Office
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 (Deposit Account No.) 054830
 (Amount) Yen 21,000
(List of Annexed Documents)
 (Item) Specification 1
 (Item) Drawing 1
 (Item) Abstract 1
 (General Authorization No.) 9104379
 (General Authorization No.) 9104380

(File Name)

SPECIFICATION

(Title of the Invention)

NEAR

INFRARED

ABSORPTION

MATERIAL

(What Is Claimed Is)

5 (Claim 1) A near infrared absorption material comprising:

 a transparent substrate, and

 at least a transparent resin layer formed thereon,
containing a near infrared absorption dye and a dye selectively
10 tively absorbing a light of 550 to 620 nm wavelength region.

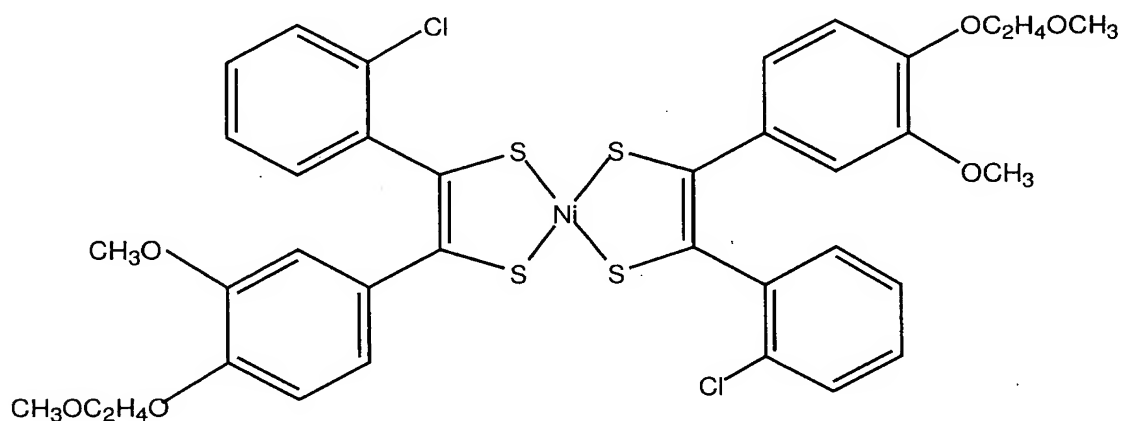
 (Claim 2) A near infrared absorption material comprising:

 a transparent substrate, and

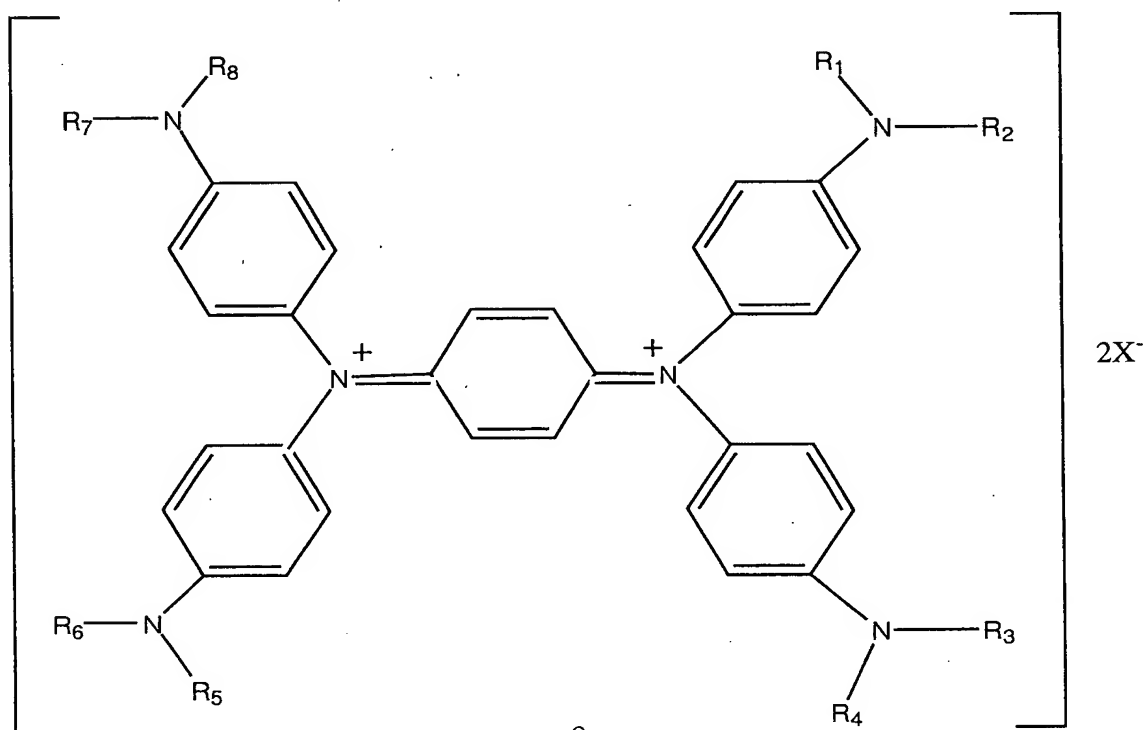
 at least a transparent resin layer containing a
15 near infrared absorption dye and an adhesive layer containing
a dye selectively absorbing a light of 550 to 620 nm wavelength region, both formed on the transparent substrate so
that the adhesive layer becomes the outermost layer.

 (Claim 3) A near infrared absorption material according to Claim 1 or 2, wherein the near infrared absorption dye
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is a dithiol-nickel complex represented by the following formula (1):

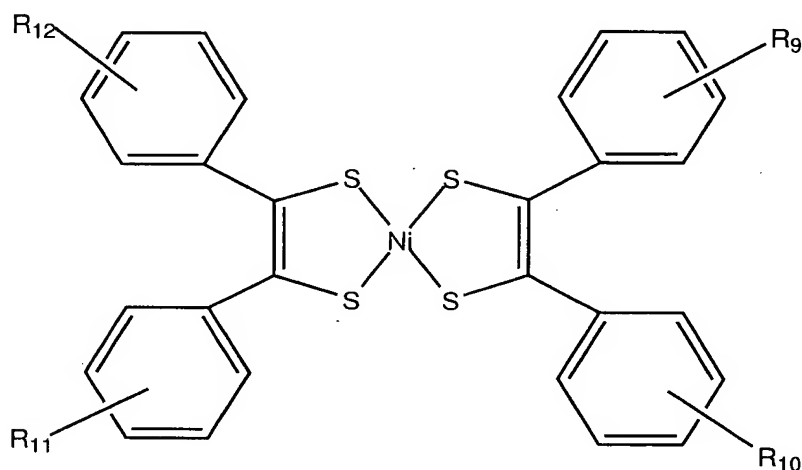


5 and at least one kind of diimonium compound represented by the following general formula (2):



(wherein R_1 to R_8 may be the same or different and are each a hydrogen atom, a C_{1-12} alkyl group or a C_{6-12} aryl group; and X is an anion typified by SbF_6^- , ClO_4^- , NO_3^- or a halogen ion).

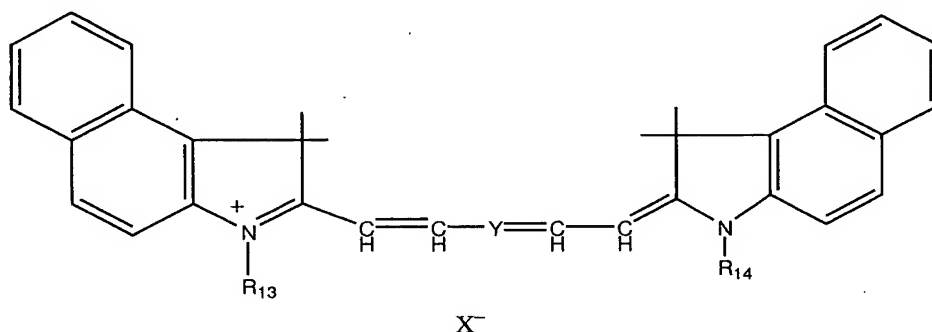
5 (Claim 4) A near infrared absorption material according to any of Claims 1 to 3, which further contains at least one kind of dithiol-nickel complex represented by the following general formula (3):



10 (wherein R_9 to R_{12} may be the same or different and are each a hydrogen atom, a C_{1-4} alkylene group, an aryl group, an aralkyl group, an alkylamino group, an alkoxy group or a halogen atom).

15 (Claim 5) A near infrared absorption material accord-

ing to any of Claims 1 to 3, which further contains at least one kind of polymethine dye represented by the following general formula (4):

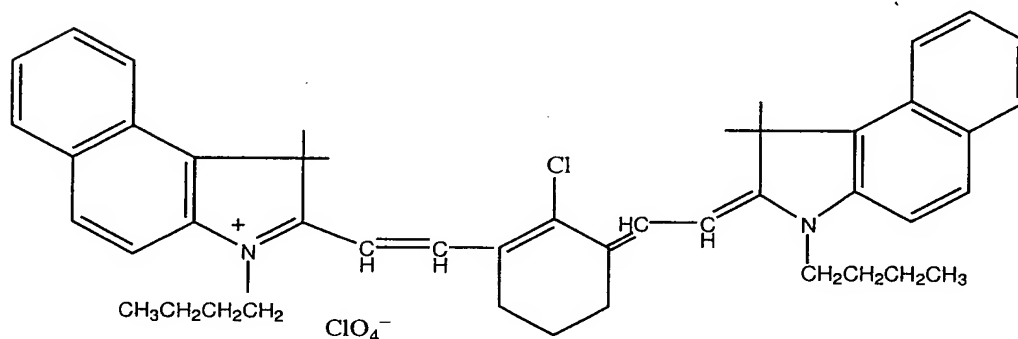


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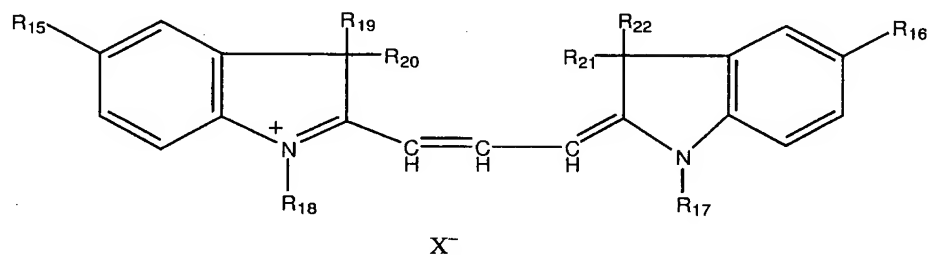
(wherein R_{13} and R_{14} may be the same or different and are each a hydrogen atom, a C_{1-12} alkyl group, a C_{6-12} aryl group, an alkenyl group, an aralkyl group or an alkynyl group; Y is a sulfur atom, a methine group or a chlorocyclohexene group; and X is an anion typified by SbF_6^{-} , ClO_4^{-} , NO_3^{-} or a halogen ion).

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(Claim 6) A near infrared absorption material according to Claim 5, wherein the polymethine dye is represented by the following general formula (5):



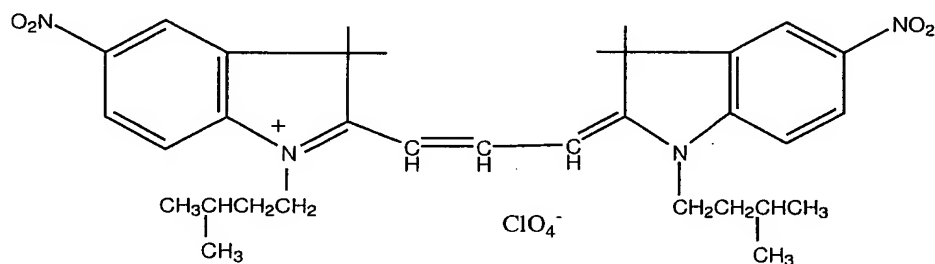
(Claim 7) A near infrared absorption material according to any of Claims 1 to 3, wherein the dye selectively absorbing a light of 550 to 620 nm wavelength region is at least one kind of cyanin dye represented by the following general formula (6):



(wherein R_{15} , R_{16} , R_{19} , R_{20} , R_{21} and R_{22} may be the same or different and are each a hydrogen atom, a C_{1-12} alkyl or alkoxy group, an amino group, a cyano group, a nitro group or a carboxyl group; R_{17} and R_{18} may be the same or different and are

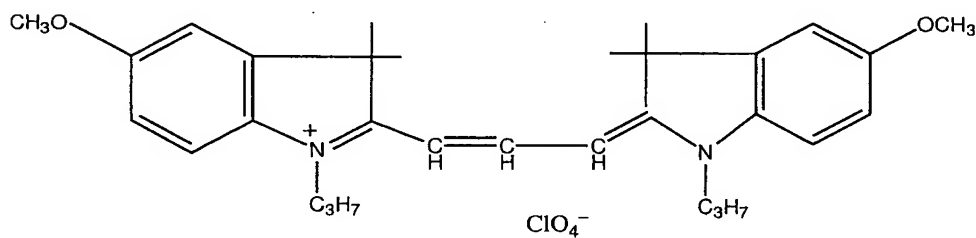
each a hydrogen atom, a C₁₋₁₂ alkyl group, a C₆₋₁₂ aryl group, an alkenyl group, an aralkyl group or an alkynyl group; and X is an anion typified by SbF₆⁻, ClO₄⁻, NO₃⁻ or a halogen ion).

(Claim 8) A near infrared absorption material according to Claim 7, wherein the dye selectively absorbing a light of 550 to 620 nm wavelength region is at least one dye selected from the dyes represented by the following general formula (7):



10

or the dyes represented by the following general formula (8):



(Claim 9) A near infrared absorption material accord-

ing to Claim 1 or 2, wherein the transparent substrate is made from a polycarbonate, a polyarylate or both of them.

(Claim 10) A near infrared absorption material according to Claim 1 or 2, wherein the transparent substrate is made from at least one kind selected from a polyethylene terephthalate, a polyethylene naphthalate and a cycloolefin.

(Claim 11) A filter for plasma display panel, made from a near infrared absorption material set forth in any of Claims 1 to 10.

10 (Detailed Description of the Invention)

(Field of the Invention)

The present invention relates to a near infrared absorption material.

(Description of the Prior Art)

15 In recent years, development of plasma display panel has been active and its products have been put into market. As is easily anticipated from their principle, plasma display panels emit a near infrared light during the plasma discharge; since this near infrared light is close to the
20 near infrared light used by the remote controllers of elec-

tronic appliances such as household TVs, air conditioners, video players and the like, plasma displays invite malfunctioning of the electronic appliances placed in the vicinity thereof. Hence, a near infrared absorption filter is often
5 used as a cover plate of plasma display, for absorption and shielding of a near infrared region of 800 to 1,000 nm, particularly 850 to 1,000 nm.

The above near infrared absorption filter has been produced in various forms. Recently, there has also
10 been proposed a near infrared absorption filter which selectively absorbs not only a near infrared light (absorbed by conventional filters) but also an orange light of 550 to 620 nm wavelength region (this orange light gives an unclear image), but absorbs substantially no visible light of other
15 wavelength region and therefore can give a clear image.

For example, JP-A-2000-252420 and JP-A-2000-275432 each disclose a cover plate for an image display device having a plasma display panel, which is a laminate of a transparent substrate, an antireflection layer, an electro-
20 magnetic wave-shielding layer, a near infrared absorption

layer and a layer for absorption of 560 to 620 nm wavelength light.

(Problems to be Solved by the Invention)

In the cover plate for image display disclosed in JP-A-2000-252420, the layer for absorption of 560 to 620 nm wavelength light is formed by dispersing a dye absorbing such a light, in gelatin. However, since a water-soluble gelatin is used as the gelatin, the coated layer formed shows cissing against a substrate made from a polyethylene terephthalate, polyethylene naphthalate, a polyolefin or the like, making it impossible to obtain a uniform coated layer; moreover, the near infrared absorption dye when added tends to be decomposed in gelatin by heat, humidity or the like and is low in weather resistance and durability. Thus, the cover plate disclosed in the above literature has problems.

The cover plate for image display disclosed in JP-A-2000-275432 is formed by dispersing a dye absorbing 560 to 620 nm wavelength light in a PMMA resin. However, in this case as well, the near infrared absorption dye used tends to be decomposed by heat, humidity or the like and is low in

weather resistance and durability. Thus, the cover plate disclosed in the above literature has a problem.

The present invention aims at providing a near infrared absorption material which alleviates the above-mentioned problems of the prior art, which selectively absorbs not only a near infrared light but also an orange light of 550 to 620 nm wavelength region (this orange light gives an unclear image), but absorbs substantially no visible light of other wavelength region and therefore can give a clear image, and which is superior in weather resistance and durability.

(Means to Solve the Problem)

According to the present invention, there is provided a near infrared absorption material comprising:

15 a transparent substrate, and

at least a transparent resin layer formed thereon, containing a near infrared absorption dye and a dye selectively absorbing a light of 550 to 620 nm wavelength region; or a near infrared absorption material comprising:

20 a transparent substrate, and

at least a transparent resin layer containing a near infrared absorption dye and an adhesive layer containing a dye selectively absorbing a light of 550 to 620 nm wavelength region, both formed on the transparent substrate so that the adhesive layer becomes the outermost layer.

(Detailed Description of the Invention)

The present invention is described in detail below.

The transparent substrate used in the near infrared absorption material of the present invention can be any substrate as long as a transparent resin layer can be formed thereon, and is not critical. It is preferably made from a polycarbonate, a polyarylate or both of them, in view of the dye stability mentioned later.

The transparent substrate may also be made from at least one kind selected from a polyethylene terephthalate, a polyethylene naphthalate and a polycycloolefin. When they are used, they show high solvent resistance and thermal stability; when, in particular, a polyethylene naphthalate or a cycloolefin is used and attached to a transparent substrate

such as glass or the like, interference infringe appears hardly.

The near infrared absorption material of the present invention comprises:

5 a transparent substrate, and

at least a transparent resin layer formed thereon, containing a near infrared absorption dye and a dye selectively absorbing a light of 550 to 620 nm wavelength region.

The near infrared absorption material may comprises:

10 a transparent substrate, and

at least a transparent resin layer containing a near infrared absorption dye and an adhesive layer containing a dye selectively absorbing a light of 550 to 620 nm wavelength region, both formed on the transparent substrate so

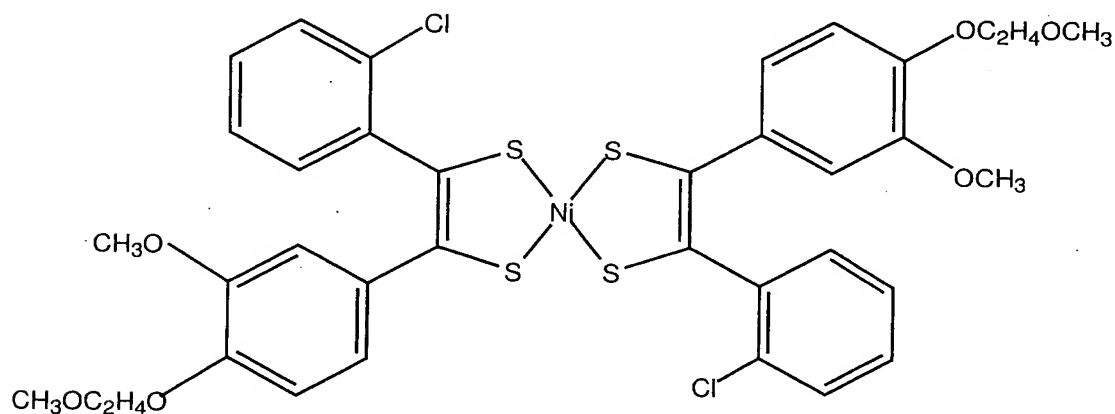
15 that the adhesive layer becomes the outermost layer.

In the near infrared absorption material of the present invention, there can be formed, in addition to the transparent resin layer (or the transparent resin layer and the adhesive layer), layers for reflection prevention, glare prevention, reflection and glare prevention, antistatic prop-

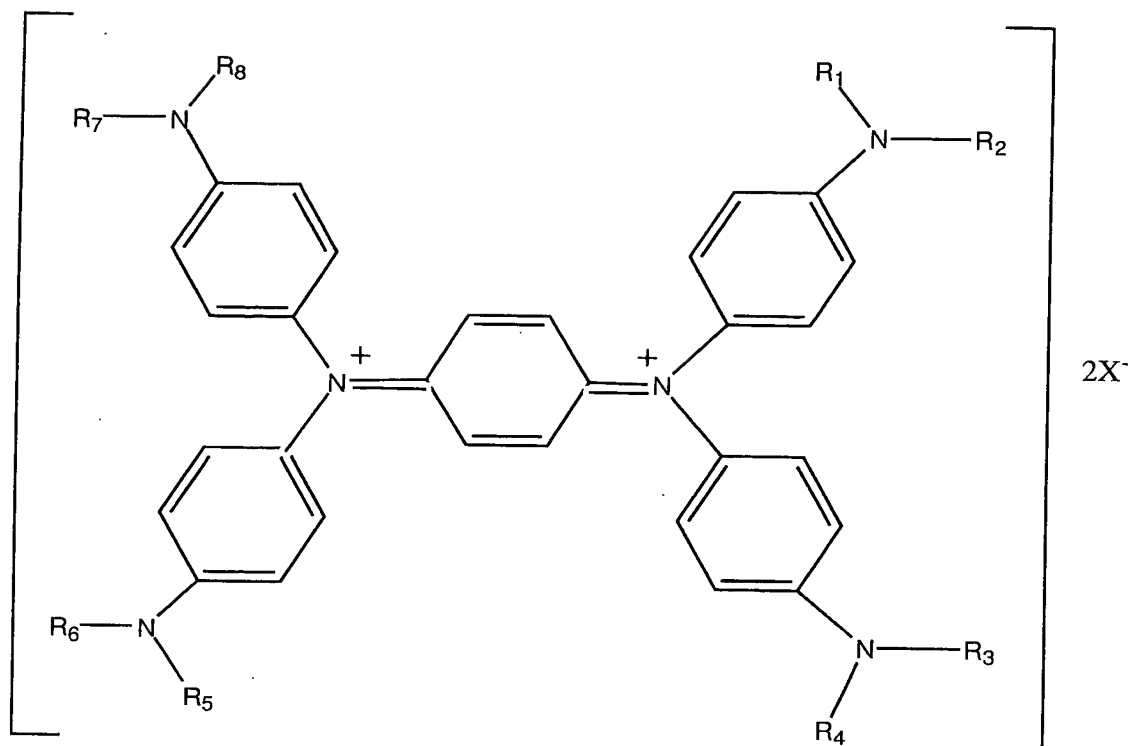
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erty, Newton's ring prevention, gas-barrier property, layers for hard coating, staining prevention, etc.

As the near infrared absorption dye used in the near infrared absorption material of the present invention, there can be mentioned, for example, a dithiol-nickel complex represented by the following formula (1):



and a least one kind of diimonium compound represented by the following general formula (2):

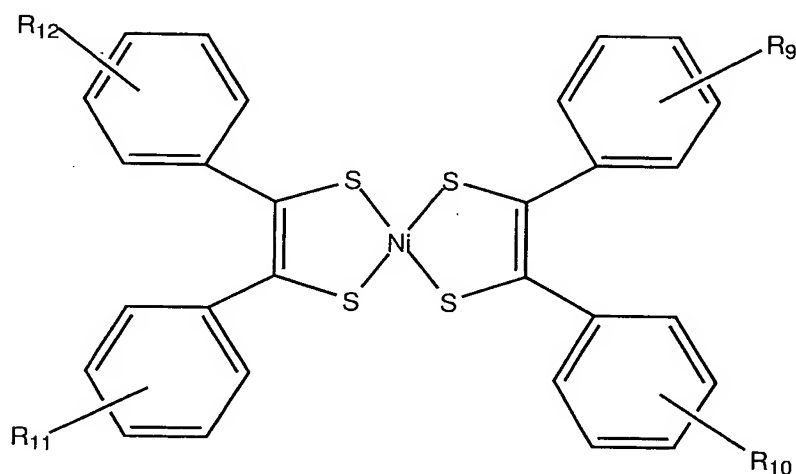


In the above general formula (2), R_1 to R_8 may be the same or different and are each a hydrogen atom, a C_{1-12} alkyl group or a C_{6-12} aryl group; and X is an anion typified
 5 by SbF_6^- , ClO_4^- , NO_3^- or a halogen ion.

The amount of the near infrared absorption dye used in the transparent resin layer can be, for example, 0.001 to 50% by weight based on the transparent resin used in the layer. When the amount of the near infrared absorption
 10 dye is far less than 0.001% by weight, the dye has low absorbability for near infrared light. When the amount is more

than 50% by weight, the dye precipitates or causes decomposition or deterioration (this results in change of absorption wavelength region). Thus, with such amounts, the intended properties cannot be met.

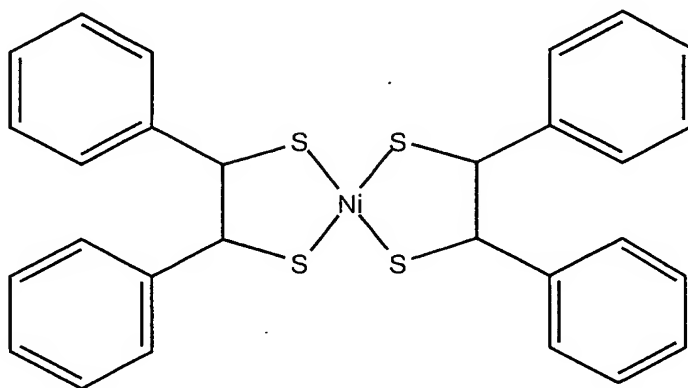
5 To the near infrared absorption dye used in the near infrared absorption material of the present invention may further be added at least one kind of dithiol-nickel complex represented by the following general formula (3).



10 In the general formula (3), R₉ to R₁₂ may be the same or different and are each a hydrogen atom, a C₁₋₄ alkylene group, an aryl group, an aralkyl group, an alkylamino group, an alkoxy group or a halogen atom.

15 The dithiol-nickel complex is preferably a

dithiol-nickel complex represented by the following formula
(9):



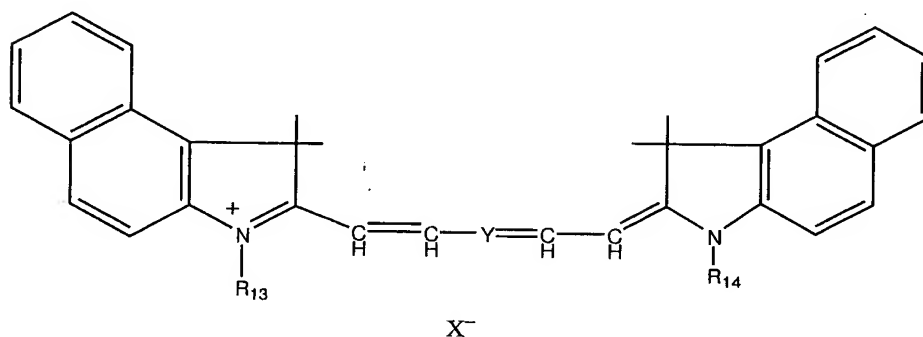
5 particularly for the absorbability for near infrared light.

The amount of the dithiol-nickel complex of the formula (9) added can be, for example, 0.001 to 100% by weight based on the transparent resin. When the amount of the dithiol-nickel complex of the formula (9) is far less than 0.001% by weight,

10 the dye has low absorbability for near infrared light. When the amount is more than 100% by weight, the dye precipitates or causes decomposition or deterioration (this results in change of absorption wavelength region). Thus, with such amounts, the intended properties cannot be met.

To the near infrared absorption dye used in the near infrared absorption material of the present invention may furthermore be added at least one kind of polymethine dye represented by the following general formula (4):

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in order to ensure the selective absorption of particular wavelengths of near infrared region.

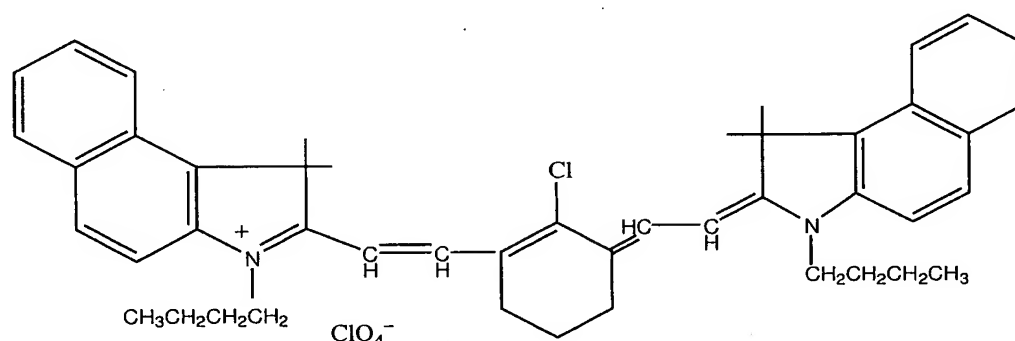
In the general formula (4), R_{13} and R_{14} may be the same or different and are each a hydrogen atom, a C_{1-12} alkyl group, a C_{6-12} aryl group, an alkenyl group, an aralkyl group or an alkynyl group; Y is a sulfur atom, a methine group or a chlorocyclohexene group; and X is an anion typified by SbF_6^- , ClO_4^- , NO_3^- or a halogen ion.

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The amount of the polymethine dye can be, for example, 0.001 to 50% by weight based on the transparent resin.

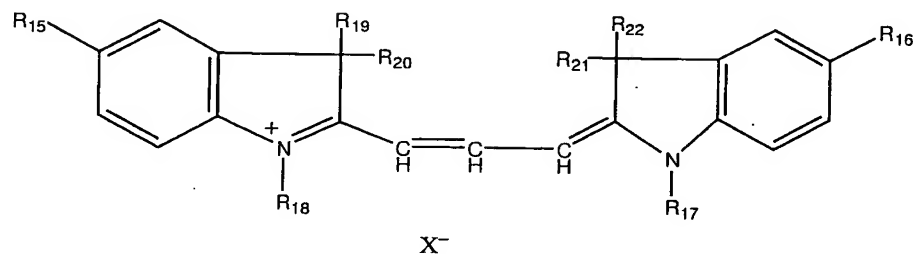
When the amount of the polymethine dye is far less than 0.001% by weight, the dye has low absorbability for near infrared light. When the amount is more than 50% by weight, the dye precipitates or causes decomposition or deterioration (this results in change of absorption wavelength region). Thus, with such amounts, the intended properties cannot be met.

As specific examples of the polymethine dye of the general formula (4), there can be mentioned compounds represented by the following formula (5):



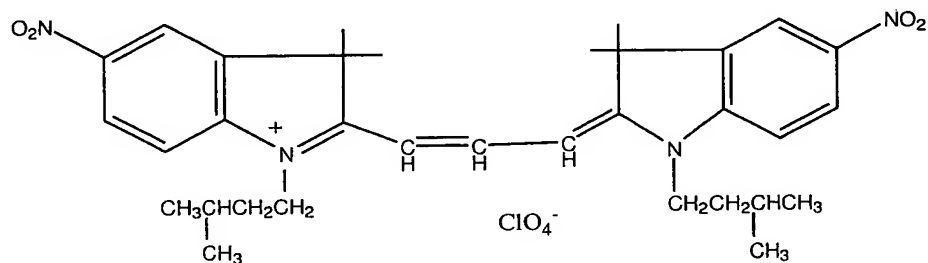
Meanwhile, as the dye selectively absorbing a light of 550 to 620 wavelength region, used in the near infrared absorption material of the present invention, there can be mentioned, for example, at least one kind of cyanin

dye represented by the following general formula (6):

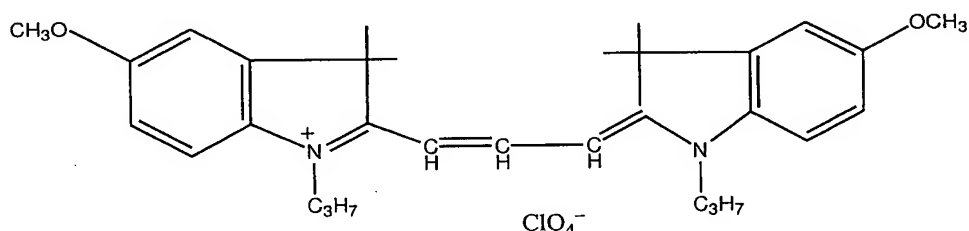


In the general formula (6), R_{15} , R_{16} , R_{19} , R_{20} , R_{21} and R_{22} may be the same or different and are each a hydrogen atom, a C_{1-12} alkyl or alkoxy group, an amino group, a cyano group, a nitro group or a carboxyl group; R_{17} and R_{18} may be the same or different and are each a hydrogen atom, a C_{1-12} alkyl group, a C_{6-12} aryl group, an alkenyl group, an aralkyl group or an alkynyl group; and X is an anion typified by SbF_6^- , ClO_4^- , NO_3^- or a halogen ion.

As specific examples of the dye selectively absorbing a light of 550 to 620 nm wavelength region, there can be mentioned at least one cyanin dye selected from the dye represented by the following general formula (7):



or the dye represented by the following general formula (8):



5

The dye selectively absorbing a light of 550 to 620 nm wavelength region can be added into either or both of the adhesive layer and the transparent resin layer. The amount of the dye added into the adhesive layer or the transparent resin layer can be, for example, 0.0001 to 50% by weight, preferably 0.0002 to 20% by weight based on the adhesive in the adhesive layer or the transparent resin in the transparent resin layer.

The method for forming the transparent resin lay-

er on the transparent substrate is not critical. The transparent resin layer can be formed, for example, by dissolving the near infrared absorption dye, the dye selectively absorbing a light of 550 to 620 nm wavelength region and the transparent resin all mentioned above, in an organic solvent compatible with them, coating the resulting solution on the above-mentioned transparent substrate using a roll coater, a die coater, a gravure cater or the like, and evaporating the organic solvent in the coated solution at room temperature or by single or combination use of ventilation, ventilation and heating, far infrared heating, electromagnetic wave heating, etc. to dry the coated solution.

The method for forming the adhesive layer is not critical, either. The adhesive layer can be formed, for example, by dissolving the near infrared absorption dye, the dye selectively absorbing a light of 550 to 620 nm wavelength region and the transparent resin all mentioned above, in an organic solvent compatible with them, coating the resulting solution on a release film by use of a roll coater, a die coater, a gravure coater or the like, evaporating the solvent

in the coated solution at room temperature or by single or combination use of ventilation, ventilation and heating, far infrared heating, electromagnetic wave heating, etc. to dry the coated solution, and laminating the resulting material on
5 a transparent substrate.

The adhesive layer is formed on the transparent resin layer or on the opposite side of the transparent substrate, as the outermost layer of the near infrared absorption material of the present invention.

10 The thickness of the transparent resin layer is 0.1 to 30 μm , preferably 0.5 to 15 μm ; and the thickness of the adhesive layer is preferably 0.1 to 50 μm .

The near infrared absorption material can be used for production of a filter for plasma display panel, by laminating it with layers for reflection prevention, glare prevention, reflection and glare prevention, antistatic property, Newton's ring prevention, gas-barrier property, layers for hard coating, staining prevention, etc., a transparent electroconductive layer and an electromagnetic wave-shielding
15 layer (a metal-made geometric pattern), by a hot press or a
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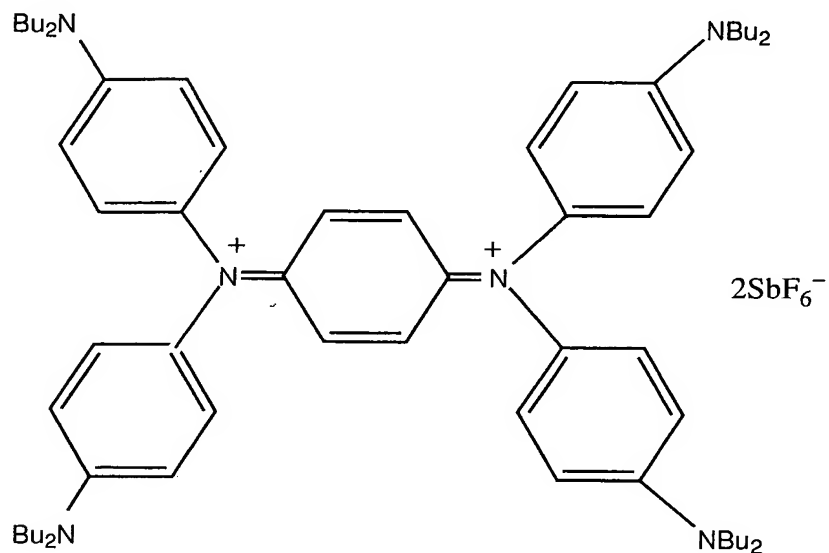
laminator, without using any adhesive or via an adhesive, an adhesive film or both of them.

(Examples)

The present invention is described in detail below by way of Production Examples, Examples and Comparative Examples.

Example 1

In 100 parts by weight of 1,3-dioxolane were dissolved 18 parts by weight of a polycarbonate resin [Panlite L1250Z (trade name), produced by Teijin Chemicals Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.2 part by weight of a dithiol-nickel complex represented by the formula (9), 0.2 part by weight of a diimonium compound dye represented by the following formula (10):



and 0.008 part by weight of a cyanin compound dye represented by the above-shown formula (7). The resulting solution was

5 cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material. The coated surface of the material was free from cissing or the

10 like and had sufficient uniformity.

The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 1 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in

Table 1 are shown the transmitted chromaticities of the near infrared absorption material before and after the heat resistance test. As seen from the spectra, an orange light region of 550 to 620 nm and a near infrared light region of 850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is good. Further, even after the heat resistance test of 500 hours, the decomposition of dyes is kept low and there is substantially no change in spectrum or chromaticity; thus, the film-shaped near infrared absorption material has sufficient heat resistance over a long period as a PDP filter.

Example 2

In 100 parts by weight of 1,3-dioxolane were dissolved 18 parts by weight of a polycarbonate resin [Panlite L1250Z (trade name), produced by Teijin Chemicals Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.2 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.2 part by weight of a diimonium compound dye represented by the above-shown formula (10) and 0.02 part by weight of a

cyanin compound dye represented by the above-shown formula (8). The resulting solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material. The coated surface of the material was free from cissing or the like and had sufficient uniformity.

The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 2 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in Table 1 are shown the transmitted chromaticities of the near infrared absorption material before and after the heat resistance test. As seen from the spectral chart, an orange light region of 550 to 620 nm and a near infrared light region of 850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is good. Further, even after the heat resistance test of 500 hours, the decomposition of dyes is kept low and there is substantially no change in spectrum

or chromaticity; thus, the film-shaped near infrared absorption material has sufficient heat resistance over a long period as a PDP filter.

Example 3

5 In 100 parts by weight of 1,3-dioxolane were dissolved 18 parts by weight of a polycarbonate resin [Panlite L1250Z (trade name), produced by Teijin Chemicals Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.2 part by weight of a dithiol-nickel complex represented by the above-shown formula (9),
10 0.2 part by weight of a diimonium compound dye represented by the above-shown formula (10) and 0.016 part by weight of a cyanin compound dye represented by the above-shown formula (6). The resulting solution was cast on a polyester film by
15 use of a bar coater having a gap distance of 100 μ m [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material. The coated surface of the material was free from cissing or the like and had sufficient
20 uniformity.

The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 3 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in Table 1 are shown the transmitted chromaticities of the near infrared absorption material before and after the heat resistance test. As seen from the spectral charts, an orange light region of 550 to 620 nm and a near infrared light region of 850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is good. Further, even after the heat resistance test of 500 hours, the decomposition of dyes is kept low and there is substantially no change in spectrum or chromaticity; thus, the film-shaped near infrared absorption material has sufficient heat resistance over a long period as a PDP filter.

Example 4

In 100 parts by weight of dichloromethane were dissolved 10 parts by weight of a polyarylate resin [U Polymer D Powder (trade name), produced by Unitika Ltd.], 0.03 part by weight of a dithiol-nickel complex represented by the

above-shown formula (1), 0.9 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.13 part by weight of a diimonium compound dye represented by the above-shown formula (10) and 0.075 part by weight of a cyanin compound dye represented by the above-shown formula (7). The resulting solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material. The coated surface of the material was free from cissing or the like and had sufficient uniformity.

The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 4 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in Table 1 are shown the transmitted chromaticities of the near infrared absorption material before and after the heat resistance test. As seen from the spectral chart, an orange light region of 550 to 620 nm and a near infrared light region of

850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is good. Further, even after the heat resistance test of 500 hours, the decomposition of dyes is kept low and there is substantially no change in spectrum or chromaticity; thus, the film-shaped near infrared absorption material has sufficient heat resistance over a long period as a PDP filter.

Example 5

In 100 parts by weight of dichloromethane were dissolved 10 parts by weight of a polyarylate resin [U Polymer D Powder (trade name), produced by Unitika Ltd.], 0.03 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.9 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.13 part by weight of a diimonium compound dye represented by the above-shown formula (10) and 0.014 part by weight of a cyanin compound dye represented by the above-shown formula (8). The resulting solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.]

and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material. The coated surface of the material was free from cissing or the like and had sufficient uniformity.

5 The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 5 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in Table 1 are shown the transmitted chromaticities of the near
10 infrared absorption material before and after the heat resistance test. As seen from the spectral chart, an orange light region of 550 to 620 nm and a near infrared light region of 850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is good. Further, even after the
15 heat resistance test of 500 hours, the decomposition of dyes is kept low and there is substantially no change in spectrum or chromaticity; thus, the film-shaped near infrared absorption material has sufficient heat resistance over a long period as a PDP filter.

20 Example 6

In 100 parts by weight of dichloromethane were dissolved 10 parts by weight of a polyarylate resin [U Polymer D Powder (trade name), produced by Unitika Ltd.], 0.03 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.9 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.13 part by weight of a diimonium compound dye represented by the above-shown formula (10) and 0.012 part by weight of a cyanin compound dye represented by the above-shown formula (6). The resulting solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μ m [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material. The coated surface of the material was free from cissing or the like and had sufficient uniformity.

The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 6 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in

Table 1 are shown the transmitted chromaticities of the near infrared absorption material before and after the heat resistance test. As seen from the spectral chart, an orange light region of 550 to 620 nm and a near infrared light region of 850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is good. Further, even after the heat resistance test of 500 hours, the decomposition of dyes is kept low and there is substantially no change in spectrum or chromaticity; thus, the film-shaped near infrared absorption material has sufficient heat resistance over a long period as a PDP filter.

Example 7

In 100 parts by weight of 1,3-dioxolane were dissolved 18 parts by weight of a polycarbonate resin [Panlite L1250Z (trade name), produced by Teijin Chemicals Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.2 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.2 part by weight of a diimonium compound dye represented by the above-shown formula (10), 0.03 part by weight of a po-

lymethine compound dye represented by the above-shown formula (5) and 0.015 part by weight of a cyanin compound dye represented by the above-shown formula (7). The resulting solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material. The coated surface of the material was free from cissing or the like and had sufficient uniformity.

10 The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 7 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in Table 1 are shown the transmitted chromaticities of the near
15 infrared absorption material before and after the heat resistance test. As seen from the spectral charts, an orange light region of 550 to 620 nm and a near infrared light region of 850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is good. Further, even after
20 the heat resistance test of 500 hours, the decomposition of

dyes is kept low and there is substantially no change in spectrum or chromaticity; thus, the film-shaped near infrared absorption material has sufficient heat resistance over a long period as a PDP filter.

5 Example 8

In 100 parts by weight of 1,3-dioxolane were dissolved 18 parts by weight of a polycarbonate resin [Panlite L1250Z (trade name), produced by Teijin Chemicals Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the
10 above-shown formula (1), 0.2 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.2 part by weight of a diimonium compound dye represented by the above-shown formula (10), 0.03 part by weight of a polymethine compound dye represented by the above-shown formula
15 (5) and 0.015 part by weight of a cyanin compound dye represented by the above-shown formula (7). The resulting solution was cast on a polyethylene naphthalate by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at
20 90°C for 3 minutes to obtain a film-shaped near infrared ab-

sorption material. The coated surface of the material was free from cissing or the like and had sufficient uniformity.

The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours.

5 The spectra and transmitted chromaticities of the near infrared absorption material before and after the heat resistance test were about the same as those of Example 7. As seen from the spectral chart, an orange light region of 550 to 620 nm and a near infrared light region of 850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is
10 good; further, even after the heat resistance test of 500 hours, the decomposition of dyes is kept low and there is substantially no change in spectrum or chromaticity, therefore, the film-shaped near infrared absorption material has
15 sufficient heat resistance over a long period as a PDP filter.

The film-shaped near infrared absorption material was cut into a size of 200 mm x 200 mm and attached, by hot pressing, to a glass plate, a transparent acrylic resin plate and a transparent polycarbonate plate each of 200 mm x 200 mm
20 x 2 mm (thickness). No interference fringe appeared. Fur-

ther, the near infrared absorption material cut into the above size was attached, by hot pressing, to each of the above transparent plates with a meltable pressure-sensitive film interposed between the near infrared absorption material and the transparent plate. No interference fringe appeared. Furthermore, a pressure-sensitive adhesive was placed on the near infrared absorption material cut into the above size, and each of the above transparent plates was attached to the pressure-sensitive adhesive. No interference fringe appeared.

10 Example 9

In 100 parts by weight of 1,3-dioxolane were dissolved 18 parts by weight of a polycarbonate resin [Panlite L1250Z (trade name), produced by Teijin Chemicals Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.2 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.2 part by weight of a diimonium compound dye represented by the above-shown formula (10), 0.03 part by weight of a polymethine compound dye represented by the above-shown formula (5) and 0.015 part by weight of a cyanin compound dye repre-

sented by the above-shown formula (7). The resulting solution was cast on a polycycloolefin film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 5 90°C for 3 minutes to obtain a film-shaped near infrared absorption material. The coated surface of the material was free from cissing or the like and had sufficient uniformity.

The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. 10 The spectra and transmitted chromaticities of the near infrared absorption material before and after the heat resistance test were about the same as those of Example 7. As seen from the spectral charts, an orange light region of 550 to 620 nm and a near infrared light region of 850 to 1,000 nm are sufficiently shielded and the transmittance for visible light is 15 good; further, even after the heat resistance test of 500 hours, the decomposition of dyes is kept low and there is substantially no change in spectrum or chromaticity, therefore, the film-shaped near infrared absorption material has 20 sufficient heat resistance over a long period as a PDP filter.

The film-shaped near infrared absorption material was cut into a size of 200 mm x 200 mm and attached, by hot pressing, to a glass plate, a transparent acrylic resin plate and a transparent polycarbonate plate each of 200 mm x 200 mm x 2 mm (thickness). No interference fringe appeared. Further, the near infrared absorption material cut into the above size was attached, by hot pressing, to each of the above transparent plates with a meltable pressure-sensitive film interposed between the near infrared absorption material and the transparent plate. No interference fringe appeared. Furthermore, a pressure-sensitive adhesive was placed on the near infrared absorption material cut into the above size, and each of the above transparent plates was attached to the pressure-sensitive adhesive. No interference fringe appeared.

15 Comparative Example 1

In 100 parts by weight of dichloromethane were dissolved 22.2 parts by weight of a polymethyl methacrylate [Acrypet (trade name), produced by Mitsubishi Rayon Co., Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.2 part by weight of

a dithiol-nickel complex represented by the above-shown formula (9), 0.27 part by weight of a diimmonium compound dye represented by the above-shown formula (10) and 0.0075 part by weight of a cyanin compound dye represented by the above-shown formula (7). The resulting solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material.

10 The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 8 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in Table 1 are shown the transmitted chromaticities of the near
15 infrared absorption material before and after the heat resistance test. As seen from the spectral chart, after the heat resistance test of 500 hours, absorption particularly in 900 nm or more is weak due to the decomposition of dyes and, moreover, change in chromaticity is large.

20 Comparative Example 2

In 100 parts by weight of dichloromethane were dissolved 22.2 parts by weight of a polymethyl methacrylate [Acrypet (trade name), produced by Mitsubishi Rayon Co., Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.2 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.27 part by weight of a diimmonium compound dye represented by the above-shown formula (10) and 0.0014 part by weight of a cyanin compound dye represented by the above-shown formula (8). The resulting solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material.

The film-shaped near infrared absorption material was subjected to a heat resistance test of 90°C x 500 hours. In Fig. 9 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in Table 1 are shown the transmitted chromaticities of the near infrared absorption material before and after the heat resis-

tance test. As seen from the spectral charts, after the heat resistance test of 500 hours, absorption particularly in 900 nm or more is weak due to the decomposition of dyes and, moreover, change in chromaticity is large.

5 Comparative Example 3

In 100 parts by weight of dichloromethane were dissolved 22.2 parts by weight of a polymethyl methacrylate [Acrypet (trade name), produced by Mitsubishi Rayon Co., Ltd.], 0.07 part by weight of a dithiol-nickel complex represented by the above-shown formula (1), 0.2 part by weight of a dithiol-nickel complex represented by the above-shown formula (9), 0.27 part by weight of a diimonium compound dye represented by the above-shown formula (10) and 0.012 part by weight of a cyanin compound dye represented by the above-shown formula (6). The resulting solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.] and dried at 90°C for 3 minutes to obtain a film-shaped near infrared absorption material.

20 The film-shaped near infrared absorption material

was subjected to a heat resistance test of 90°C x 500 hours.

In Fig. 10 are shown the spectra of the near infrared absorption material before and after the heat resistance test; in Table 1 are shown the transmitted chromaticities of the near infrared absorption material before and after the heat resistance test. As seen from the spectral charts, after the heat resistance test of 500 hours, absorption particularly in 900 nm or more is weak due to the decomposition of dyes and, moreover, change in chromaticity is large.

10 Comparative Example 4

A 20 wt. % aqueous gelatin solution was cast on a polyester film by use of a bar coater having a gap distance of 100 μm [Doctor Blade YD-2 (trade name), produced by Yoshimitsu Seiki K.K.]. However, no uniform coated layer was formed owing to cissing.

The dyes of the formulas (1), (7), (8), (9) and (10) were insoluble in water.

Table 1

Transmitted chromaticities before and after heat resistance test

		Y	x	Y	x	Δx	Δy
Example 1	0 hours	67.14	0.3028	0.3148			
	500 hours	67.02	0.3028	0.3148	0		0.0001
Example 2	0 hours	70.04	0.3011	0.3023			
	500 hours	69.94	0.3009	0.3024	-0.0002		0.0001
Example 3	0 hours	64.99	0.2978	0.3194			
	500 hours	65.52	0.2982	0.3199	0.0004		0.0005
Example 4	0 hours	79.11	0.3068	0.3186			
	500 hours	79.34	0.3072	0.3191	0.0004		0.0005
Example 5	0 hours	67.51	0.2964	0.2982			
	500 hours	67.72	0.2970	0.2988	0.0006		0.0006
Example 6	0 hours	35.90	0.2135	0.2227			
	500 hours	35.77	0.2139	0.2233	0.0004		0.0005
Example 7	0 hours	65.26	0.3024	0.3176			
	500 hours	65.51	0.3028	0.3183	0.0004		0.0007
Comparative Example 1	0 hours	62.36	0.3044	0.3142			
	500 hours	62.94	0.3111	0.3272	0.0067		0.0130
Comparative Example 2	0 hours	48.52	0.2914	0.2733			
	500 hours	49.11	0.2986	0.2855	0.0072		0.0122
Comparative Example 3	0 hours	66.27	0.3057	0.3253			
	500 hours	66.33	0.3121	0.3389	0.0064		0.0316

(Advantages of the Invention)

As is clear from the above Examples and Comparative Examples, the near infrared absorption material of the present invention, which comprises a transparent substrate and at least a transparent resin layer formed thereon, containing a near infrared absorption dye and a dye selectively absorbing a light of 550 to 620 nm wavelength region, can selectively absorb an orange light of 550 to 620 nm wavelength region; therefore, the near infrared absorption material enables taking-out of required RGB lights from plasma display panel or the like and can give a color of improved purity.

In other words, with the near infrared absorption material of the present invention, an orange light is absorbed and thereby the image of plasma display panel or the like is made clear.

Further, the near infrared absorption material of the present invention is far superior to the prior art in weather resistance (heat resistance, moisture resistance and durability).

(Brief Description of the Drawings)

Fig. 1 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material obtained in Example 1.

Fig. 2 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material obtained in Example 2.

Fig. 3 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material obtained in Example 3.

Fig. 4 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material obtained in Example 4.

Fig. 5 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material obtained in Example 5.

Fig. 6 is the spectra before and after heat resistance test, of the film-shaped the infrared absorption material obtained in Example 6.

Fig. 7 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material

al obtained in Example 7.

Fig. 8 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material obtained in Comparative Example 1.

Fig. 9 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material obtained in Comparative Example 2.

Fig. 10 is the spectra before and after heat resistance test, of the film-shaped infrared absorption material obtained in Comparative Example 3.

(File Name) Abstract of the disclosure

(Abstract)

(Object) To provide a near infrared absorption material which alleviates the problems of the prior art, which selectively absorbs not only a near infrared light but also an orange light of 550 to 620 nm wavelength region (this orange light gives an unclear image), but absorbs substantially no visible light of other wavelength region and therefore can give a clear image, and which is superior in weather resistance and durability.

(Summary) The present invention provides a near infrared absorption material comprising:

 a transparent substrate, and

 at least a transparent resin layer formed thereon, containing a near infrared absorption dye and a dye selectively absorbing a light of 550 to 620 nm wavelength region; or, comprising:

 a transparent substrate, and

 at least a transparent resin layer containing a

near infrared absorption dye and an adhesive layer containing a dye selectively absorbing a light of 550 to 620 nm wavelength region, both formed on the transparent substrate so that the adhesive layer becomes the outermost layer.

APPLICANT'S RECORD

ID Code 000004374

1.	Date of Record	March, 30, 1993
	Reason for Record	Address Change
	Address	31-11, Nihonbashi Ningyocho 2-chome, Chuo-ku, Tokyo
	Name	Nisshinbo Industries, Inc.



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Fig.1

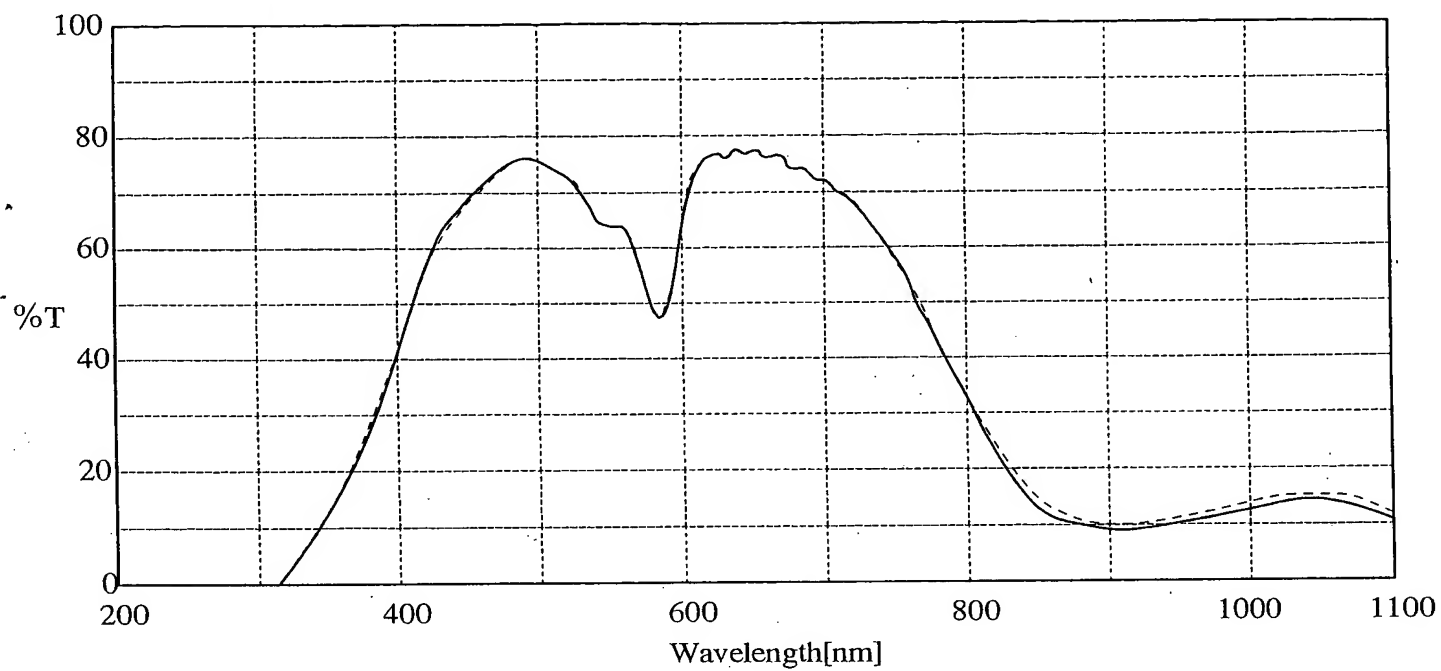
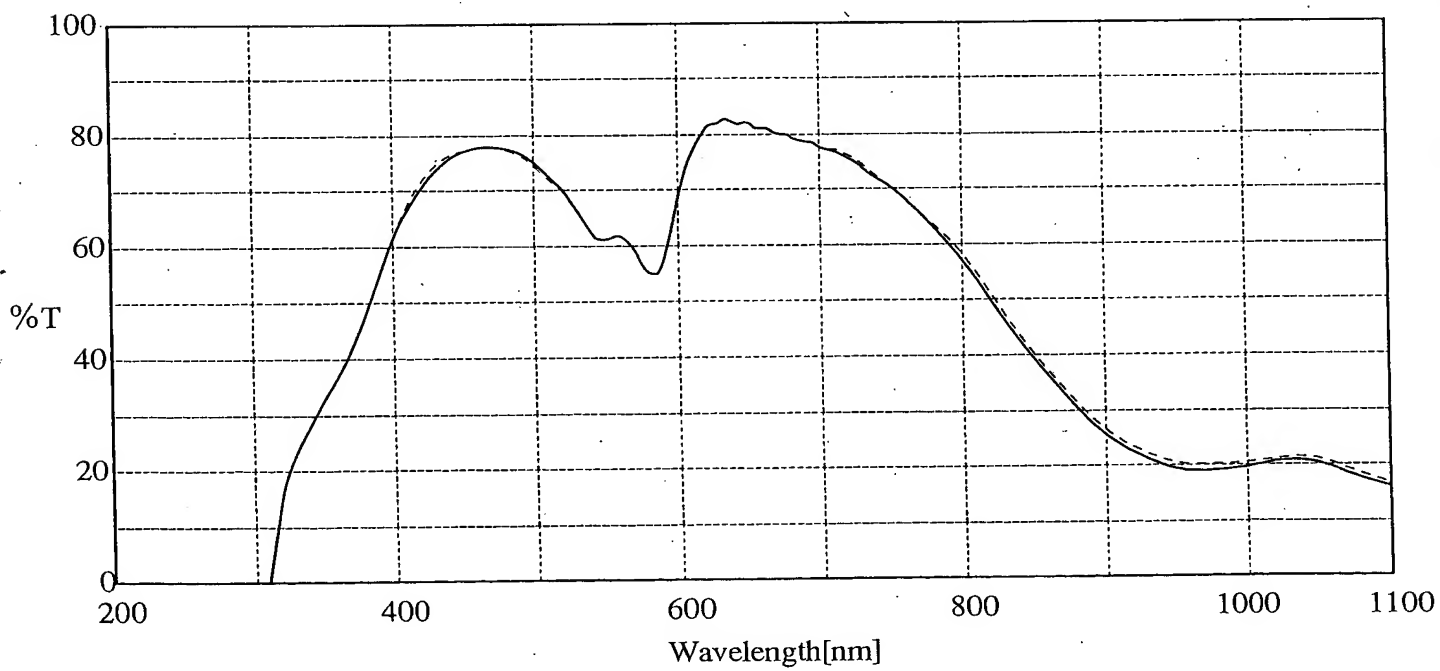


Fig.2





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Fig.3

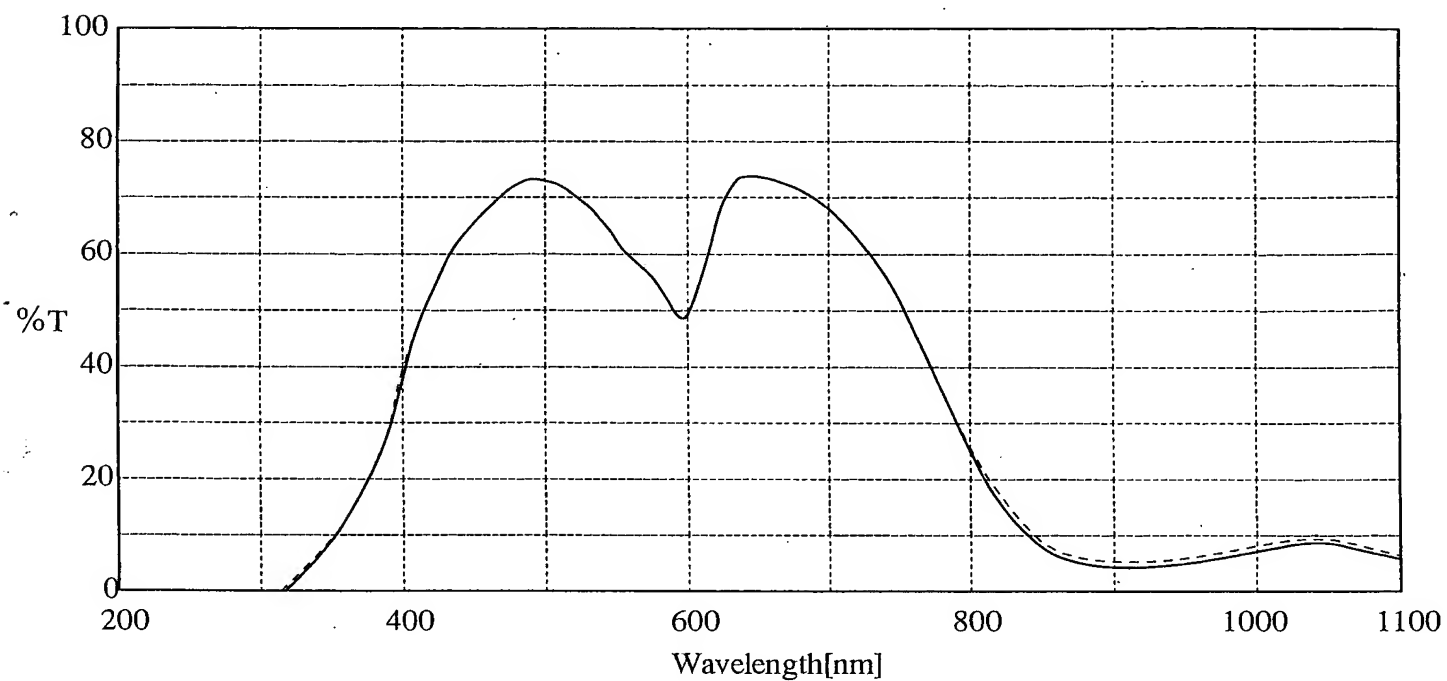
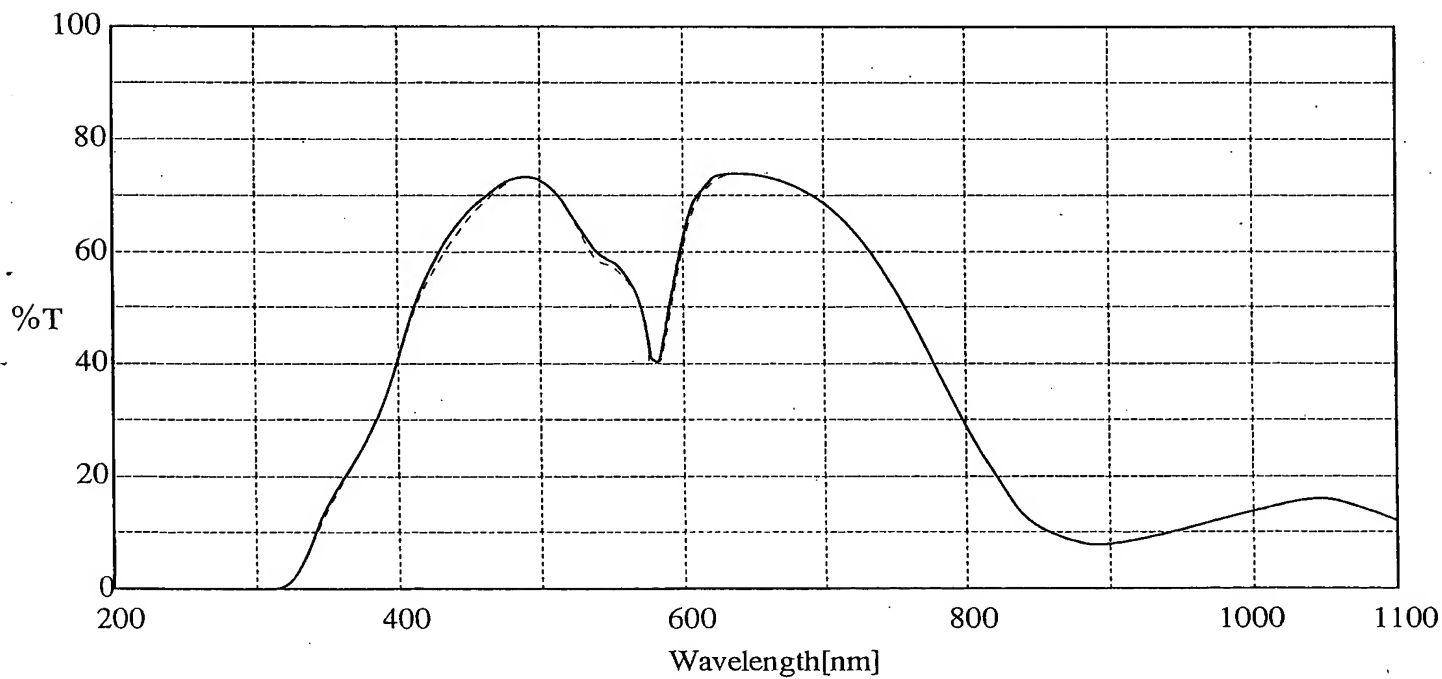


Fig.4





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Fig.5

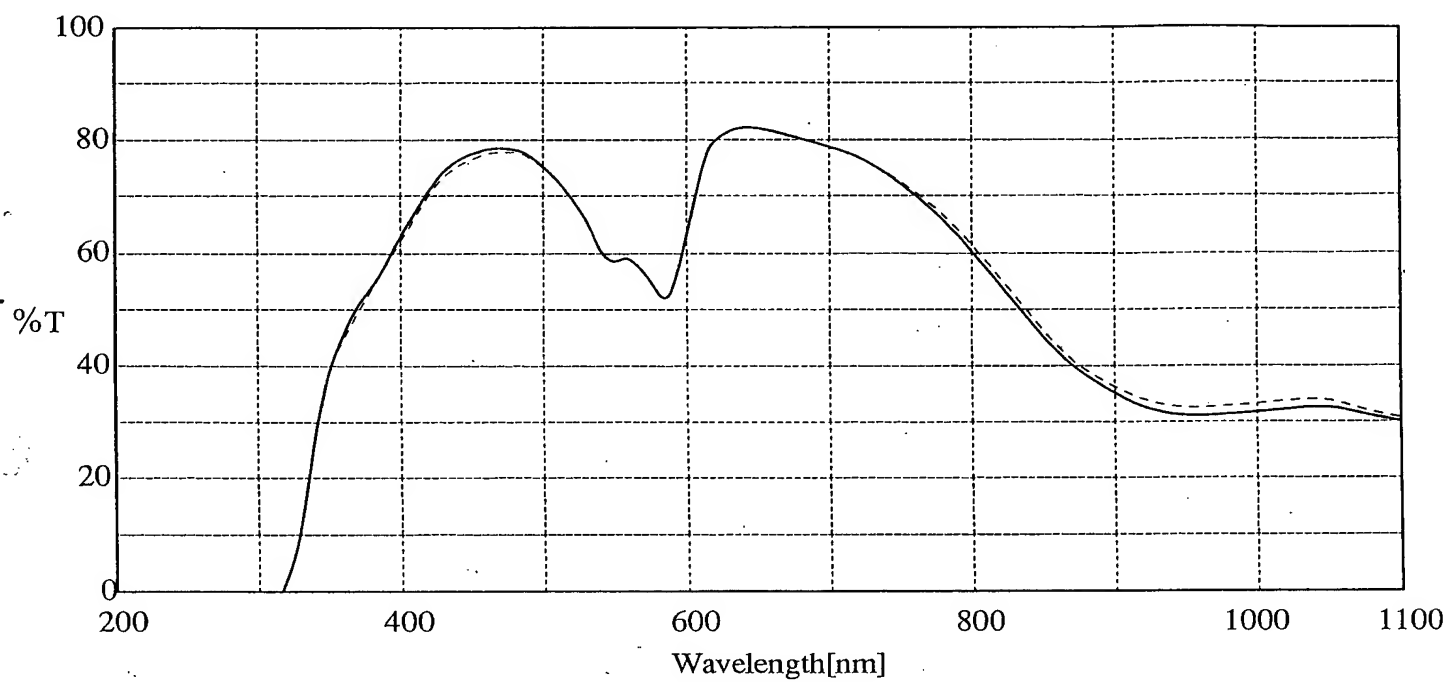
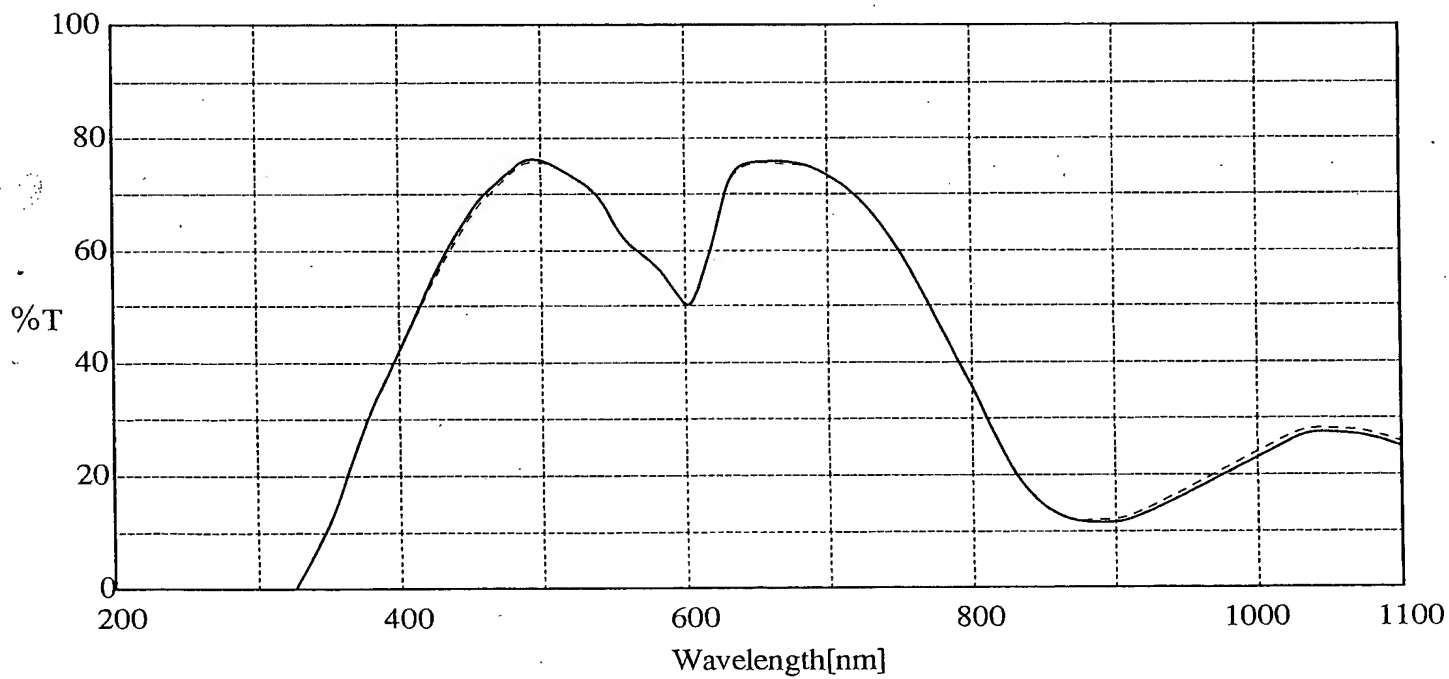


Fig.6





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Fig.7

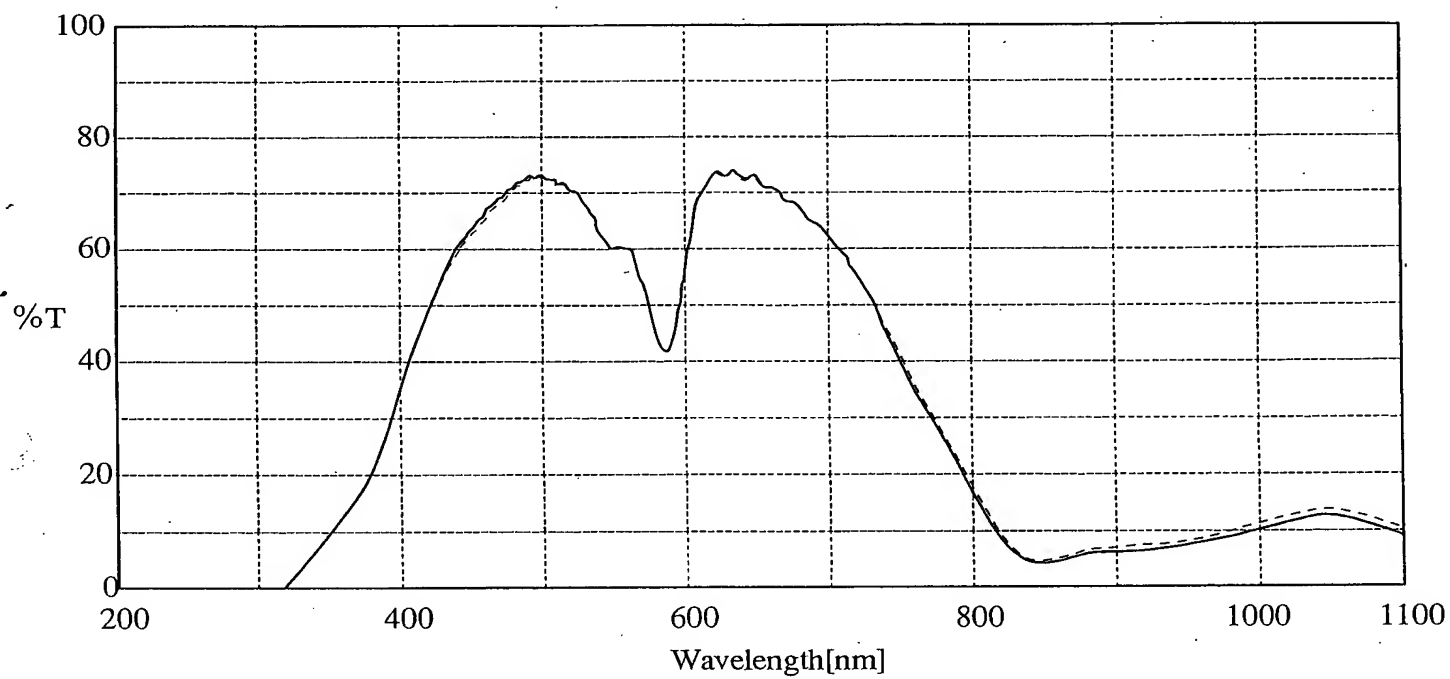
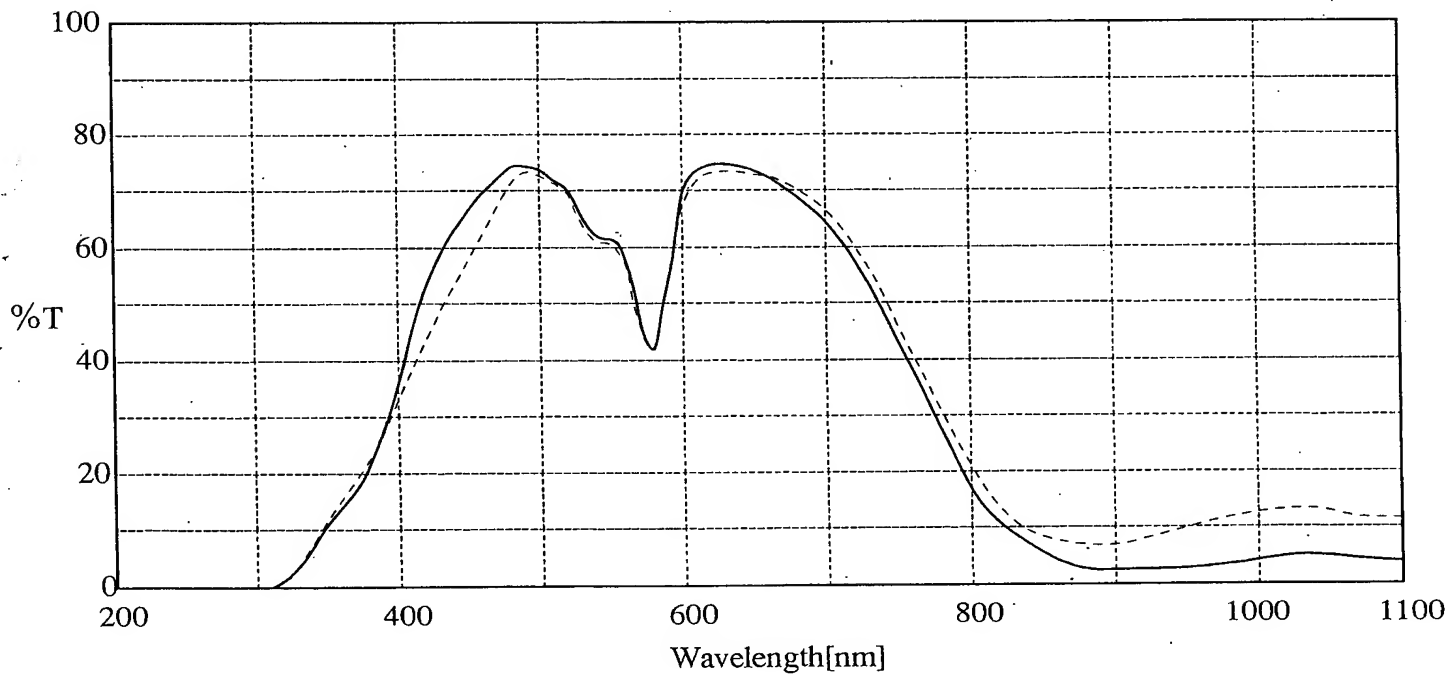


Fig.8





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Fig.9

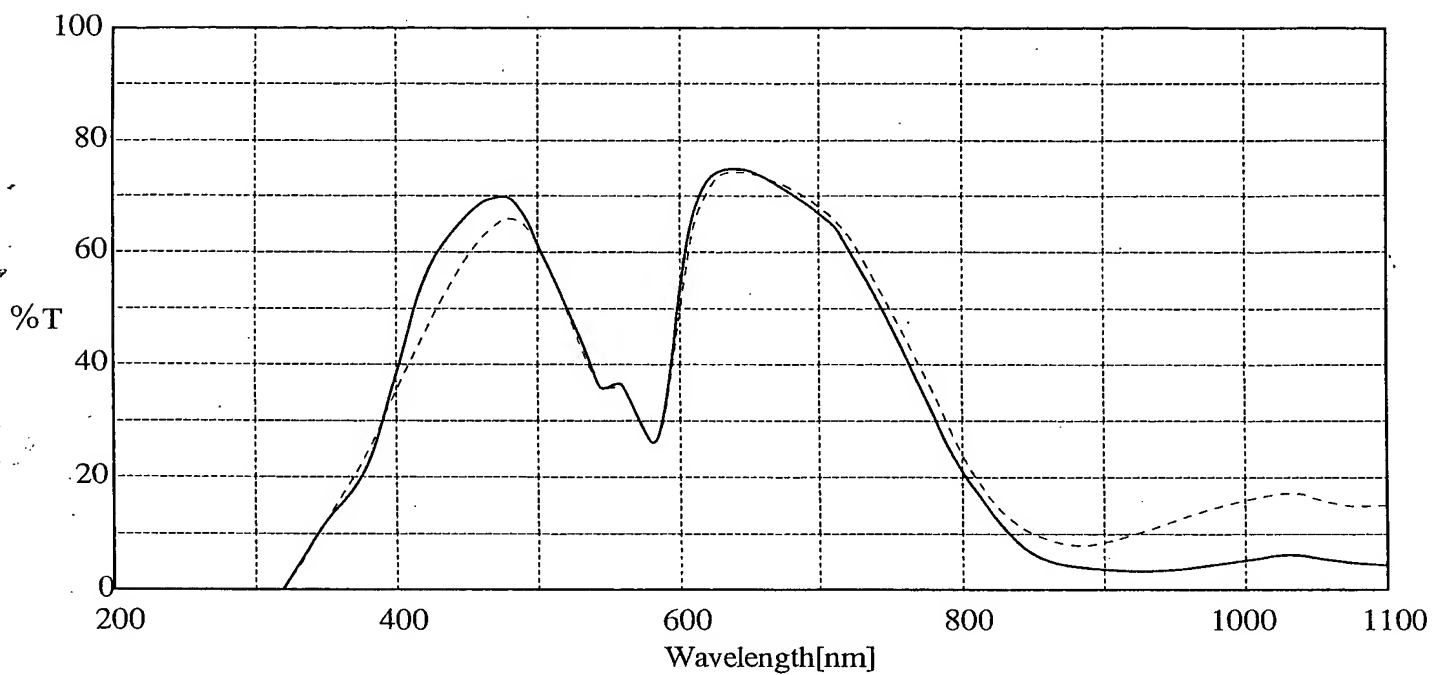


Fig.10

